

Cleaning Method – Vapor Degreasing

- Vapor Degreasing:
 A simple and Low Cost method of Cleaning production quantity parts to a high quality standard
- The equipment design has been around since the 1940's.
- Halogenated solvents (F- and or Cl-)
 - Hostile to pathogens/ does not add to bioburden
 - Solvents with low surface tension, low viscosity and good solvency strength
 - Allows for submicron filtration
 - 100% Volatile
 - Parts come out clean, dry and ready for use or package



Solvents

- Mono-Solvents
- Azeotropes
- Co-solvents



Co-Solvents

- A solvating agent and a rinse agent
 - Unique attributes (CI- free)
 - Designed solvency
 - No-Clean Fluxes
 - Other synthetics

Possibly reduced toxicity Possibly reduced Flam.



Cleaning - Submicron

- Cleaning is a process
 - Equipment
 - Through-put
 - Chemistry
 - Environment
 - White room



Equipment

Designed for sub-micron cleaning

- Sized right
- Energy addition
 - Removal
- Workload / throughput
- Compatible with cleaners
 - Filters, pumps, separators



Throughput / time

Throughput

- Lab
 - Solvent and process qualification
- Production verification
- Controlled by automation
- repeatable

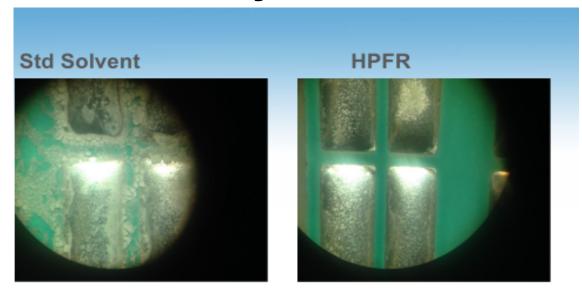


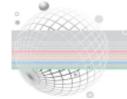
Co-solvents:

Solvating agent (New Gen)

- =Rinse agent + additive.
- stays in the boil sump.
- formulated to remove soils
- compatible











Co-solvents:

Rinse Agent

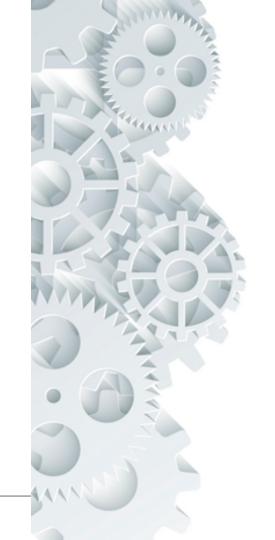
- volatilizes
- vapor and rinse
- no residues



Co-solvents:

Rinse agent is a component of the Solvating agent

- make up solvent for both sumps.
- easy to maintain
- long bath life: boil sump
- no added bioburden



Co-Solvents:

- Chlorine Free Cleaning Fluid
- High Performance Flux Remover
 - Synthetic Grease Cleaner

Hybrids:



Thank you

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